

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	85	257/E21.639 257/ E21.636	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/24 10:33
L3	16	2 and hafnium with silicate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/24 10:33
S2	2	"20030168705"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 09:47
S3	658	silicon with concentration and nitrid \$5 and hafnium with (silicide silicate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:40
S4	550	S3 and film and hafnium near\$2silicate and chamber and reaction and nitrogen	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:48
S6	91	S3 and film and hafnium near2 silicate and chamber and reaction and nitrogen	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:48
S7	21	S3 and film and hafnium near2 silicate and chamber and reaction and nitrogen and nitriding	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:54
S8	402601	"427"/\$. ccls. "438"/\$. ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:55
S9	8365	S8 and hafnium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:55

S10	446	S9 and nitrid\$5 and nitrogen and hafnium adj silicate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:56
S11	112	S10 and reaction with chamber	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:56
S12	33	S11 and silicon with concentration	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:57
S13	773	S11 and silicon with concentration hf\$1S\$1O	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:58
S14	12	S11 and silicon with concentration and hf\$1S\$1O	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:58
S15	5	"10302752"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:59
S16	12	10/302752	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/07 10:59
S17	1	hafnium adj silicate and silicon with source and hafnium with source and nitriding and nitrogen and silicon and liquid with source and chamber and reaction	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/09 13:42
S18	7	hafnium adj silicate and silicon with source and hafnium with source and nitriding and nitrogen and silicon and chamber and reaction	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/09 13:42

S19	16	hafnium adj silicate and silicon with source and hafnium with source and nitriding and nitrogen and silicon	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/09 13:48
S20	9	S19 not S18	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/09 13:48
S21	753	438/775	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:17
S22	88	hafnium adj silicate and silicon with source and hafnium with source and nitrogen and silicon	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:17
S23	1	S22 and S21	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:17
S24	152	silicate and silicon with source and hafnium with source and nitrogen and silicon	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:31
S25	1830	438/763	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:31
S26	640	438/762	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:31
S27	2539	438/758	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:31
S28	4568	S25 S26 S27	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:31

S29	9	S28 and S24	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:31
S30	50	2004/ 0043569	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:34
S31	3	"20040043569"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:35
S32	2	S24 and S21	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:37
S33	2	"20020172768"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:38
S34	1550	438/785	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:41
S35	30	S34 and S24	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:41
S36	2	"20020195643"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/10/10 16:48
S37	1	(hafnium and silicon and (hafnium with silicate) and chamber and vapor\$5 with (source silicon hafnium) and (mix\$3 with ratio)).dlm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/23 17:46

S38	12	(hafnium and silicon and (hafnium with silicate) and chamber and vapor\$5 with (source silicon hafnium)).dm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/23 18:01
S39	40	(hafnium and silicon and (hafnium with silicate) and vapor\$5 with (source silicon hafnium)).dm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/23 18:11
S40	7	(hafnium and silicon and (hafnium with silicate) and vapor\$5 with (source silicon hafnium) and ratio).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/23 18:11

2/24/2009 10:34:03 AM

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